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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/728,801 12/08/2003 Tatsuro Nagahara FN4104US-CIP 8923 11/16/2004 EXAMINER Alan P. Kass Clariant Corporation LEE, SIN J 70 Meister Avenue ART UNIT PAPER NUMBER Somerville, NJ 08876 1752

DATE MAILED: 11/16/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Amaliantina N	· · · · · · · · · · · · · · · · · · ·
	Application No.	Applicant(s)
Office Action Summary	10/728,801	NAGAHARA ET AL.
	Examiner	Art Unit
The MAILING DATE of this communication	Sin J. Lee	1752
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply		
A SHORTENED STATUTORY PERIOD FOR REI THE MAILING DATE OF THIS COMMUNICATION Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, and If NO period for reply is specified above, the maximum statutory perions Failure to reply within the set or extended period for reply will, by state any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a re reply within the statutory minimum of thirty ind will apply and will expire SIX (6) MONT	eply be timely filed (30) days will be considered timely. THS from the mailing date of this communication
Status		
1) Responsive to communication(s) filed on <u>08</u>) D	
	<u>B December 2003</u> . his action is non-final.	
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is		
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.		
Disposition of Claims	,	11, 400 0.0. 210.
4) Claim(s) <u>1-19</u> is/are pending in the application		
4a) Of the above claim(s) is/are withdrawn from consideration.		
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>1-19</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/or election requirement.		
Application Papers	•	
9) The specification is objected to by the Examiner.		
10) The drawing(s) filed on 08 December 2003 is/orc; a) The drawing(s)		
10) The drawing(s) filed on <u>08 December 2003</u> is/are: a) accepted or b) objected to by the Examiner.		
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).		
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.		
Priority under 35 U.S.C. § 119	Manney Color and attached C	Trice Action or form PTO-152.
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)⊠ All b)□ Some * c)□ None of:		
,		
and a solution of the phority documents have been received.		
 2. Certified copies of the priority documents have been received in Application No. <u>09/806,852</u>. 3. Copies of the certified copies of the priority documents have been received in this National Stage 		
application from the International Burea	ority documents have been red	ceived in this National Stage
* See the attached detailed Office action for a list	t of the certified copies not rec	
The state of the dominated topics not received.		
Allerton		
Attachment(s) 1) Notice of References Cited (PTO-892)	_	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Sumi	mary (PTO-413) ail Date
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Inform 6) Other:	mal Patent Application (PTO-152)

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 1-19 are rejected under 35 U.S.C. 102(b) as being anticipated by
 Nagahara et al (JP 2000-181069 and its machine-assisted English translation provided by Japan Patent Office).

Nagahara teaches a photosensitive polysilazane composition which contains a polysilazane and a photoacid generating agent (see abstract of the English translation). According to PTO's on-site oral English translation, in [4] and [5], Nagahara teaches a photosensitive polysilazane composition in which the polysilazane is mainly a polysilazane having a number average molecular weight of 100 to 100,000 that contains the skeleton represented with the formula $-(SiR^4(NR^5)_{1.5})_{n^-}$ in which R^4 is a methyl group or phenyl group, and R^5 is a H atom. Nagahara's formula $-(SiR^4(NR^5)_{1.5})_{n^-}$, in which R^4 is a methyl group or phenyl group, and R^5 is a H atom, teaches present polysiloxazane that contains as its main repeating unit $-(RSi(NR^6)_{1.5})$ - (because present R can be an alkyl group or an aryl group and present R^6 can be a H atom) as well as present polysilazane that mainly contains the skeleton of present formula (II) (because present R^4 can be an alkyl group or an aryl group and present R^5 can be a H atom).

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Nagahara also teaches that a peroxide such as t-butylperoxy benzoate can be used as his photoacid generator (see [7] and [8] of machine English translation).

Therefore, the prior art teaches present inventions of claims 1-6.

Nagahara teaches (see [9] and [10] of machine English translation) the use of a sensitizing dye such as coumarin, ketocoumarin and their derivatives and thiopyrylium salt in his photosensitive polysilazane composition. Thus, the prior art teaches present inventions of claims 7 and 8.

In [11] and [12], Nagahara furthermore teaches that an oxidation catalyst such as propionic-acid palladium can be used in his photosensitive polysilazane composition.

Therefore, the prior art teaches present inventions of claims 9 and 10.

Nagahara teaches ([0010] and [0011) a process of forming patternized polysilazane film by imagewise irradiating light and performing subsequent development. Nagahara furthermore teaches that the patternized polysilazane film can be converted into a silica system ceramic coat by being left in the ambient atmosphere or by calcinating. Thus, prior art teaches present inventions of claims 11-19.

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sin J. Lee whose telephone number is 571-272-1333. The examiner can normally be reached on Monday-Friday from 9:00 am EST to 5:30 pm EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Cynthia Kelly, can be reached on 571-272-1526. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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S.J.L.

S. Lee

October 1, 2004

Sin J. Lu

Patent Exammer

Technology Center 1700